

# THE KENYA POLYTECHNIC UNIVERSITY COLLEGE

# DEPARTMENT OF INSTITUTIONAL MANAGEMENT DIPLOMA IN CLOTHING TECHNOLOGY END OF YEAR I EXAMINATIONS NOVEMBER 2007 SERIES

### PATTERN DRAFTING PRACTICAL

## 4 hours

#### **Instructions to Candidates**

- A You should have the following for this examination.
  - H pencils
  - 30cm ruler
  - ½ scale ruler
  - French curves
  - Tracing wheel
  - Paper scissors
  - Set squares
  - Eraser
  - Glue
  - Pins
- B You will be provided with the following
  - Plain paper size A4
  - Bodice and sleeve block
- C All stages of development must be shown on the answer sheet. Final patterns must have all pattern instruction.

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# **TASK**

1. Using the measurements provided, draft patterns for the tailored skirt block

Measurements

Waist 68cm
Hips 93cm
Waist to Hips 20.6cm
Skirt length 60cm

2. Trace out the child's bodice and sleeve block provided and develop patterns for the dress style sketched below